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Organic pollutant degradation for micro-molecule product emission over SiO₂ layers-coated g-C₃N₄ photocatalysts

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In this study, a SiO₂ layer-coated g-C₃N₄ catalyst was prepared by a sol-gel method to overcome the poor adsorption ability and high recombination rate of charge carriers of pristine g-C₃N₄. SEM and TEM images indicated that SiO₂ nanoparticles were coated on the surface of g-C₃N₄ nanoparticles with a layered structure and the layers were tightly contacted with g-C₃N₄. XRD patterns, FTIR spectra, UV-vis spectra and XPS spectra revealed that the structure of g-C₃N₄ was not destroyed and its photoelectric catalytic properties were not suppressed by the coating of SiO₂ layers. Adsorption experiments revealed that the SiO₂ layers improved the adsorption performance of g-C₃N₄ and their ratios were adjusted. The molecular weights of the final products of the degradation of RhB and antibiotics were at the micro-molecule level while the amount of g-C₃N₄ reached 1.2% of the mass fraction, which were more suitable for pollutant degradation compared with those of g-C₃N₄ due to its poor adsorption ability. The reason for this was likely that the SiO₂ layers were not only beneficial for the adsorption of pollutants and intermediate products but also for prolonging the life time of the separated electrons and holes. Finally, active trapping experiments confirmed that both the holes and superoxide radicals were the main factors in the degradation of RhB and antibiotics, with the superoxides being the most active species.

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1. Introduction

Photocatalytic organic pollutant degradation is a feasible green process to solve the environmental problems caused by the dye industry and pharmaceutical industry.¹ g-C₃N₄ is considered a promising catalyst in this regard due to its remarkable characteristics, such as environmental friendliness, low cost, and high chemical and thermal stability.²⁻⁴ Its unique two-dimensional structure with graphitic planes constructed from tri-s-triazine units is beneficial for the modification and establishment of heterojunctions.^{5,6} Additionally, its suitable band gap and redox potential makes it an ideal catalyst for splitting water for H₂ generation and the degradation of organic pollutants.⁷ However, its low specific surface area and rapid electron-hole recombination, arising from the stacked layered structure and random charge transfer, limit its adsorption property and photocatalytic activity.⁸ Especially in the degradation of organic pollutants, the intermediate products are uncontrollable and also harmful to humans and animals.¹

Aiming at controlling the intermediate products, the adsorption behaviors of catalysts are important to consider, especially for the degradation of organic pollutants and pharmaceuticals due to the complex and changeable intermediate products.⁹ To solve the above-mentioned problems, the adsorption behaviors and catalytic properties can be improved by surface modification and multi-porous structure fabrication approaches, such as exfoliating g-C₃N₄ to obtain a single/few-layered structure,¹⁰ constructing a 3D multi-porous structure,¹¹⁻¹³ and selectively breaking the hydrogen bonds of the layered structure.¹⁴ The essence of the above-mentioned approaches involves enlarging the reactive surface area,¹⁵ prolonging the active species lifetime,¹⁶ suppressing the recombination rate of the charge carriers,¹⁷ *etc.* Furthermore, noble metals (Au, Ag, Pt and Pd) are also commonly used to improve the catalytic performance of g-C₃N₄ due to their high specific surface area and unique electronic and optical properties.^{18,19} Besides, metal-organic framework materials (MOFs) are used to improve the adsorption behaviors and promote the reactive species at the same time. However, the high cost and aggregation property of the framework structure limit the application scenarios and chemical stability of the materials.²⁰ Herein, developing a photocatalyst with good chemical stability, high universality and excellent control of the intermediate products is a feasible way to solve the above issues.²¹

Weighing the advantages and disadvantages of numerous co-catalysts and catalyst carriers, silicon dioxide (SiO₂) is often

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considered a good option due to its high adsorption capacity, high chemical stability, modification property, and controllable pores and morphology.²² In particular, crystalline SiO₂ is employed in electronics manufacturing as both a semiconductor and electrical insulator due to its large surface area, regular arrangement, and adjustable pores.^{23,24} The good adsorption ability of SiO₂ means it can adsorb pollutants and intermediate products effectively, and also the improved recombination rate of charge carriers can prolong the fluorescence lifetime of the charge carriers. Herein, both the high adsorption capacity and prolonged lifetime of charge carriers can be used to absorb the intermediate products from the degradation of organic pollutants and pharmaceutical for photocatalytic performance improvement.^{22,25}

Based on the above analysis, SiO₂-loaded g-C₃N₄ (x-CN@SiO₂) was designed *via* a sol-gel method to control the intermediate products from emissions, meanwhile, the combination states of g-C₃N₄ and SiO₂ were analyzed by chemical states characterization. The adsorption properties of CN@SiO₂ toward organic pollutants, and their intermediate products and final products were studied. Finally, degradation rate, and active species and intermediate products controlling mechanism were deduced from trapping experiments.

2. Experimental

2.1 Preparation of the photocatalysts

2.1.1. Preparation of pristine g-C₃N₄. 10 g melamine was added into a crucible with a lid, which was then transferred to a muffle furnace. The crucible was heated to 550 °C within 120 min and kept at that temperature for another 180 min. Then the crucible was allowed to cool to room temperature naturally to obtain g-C₃N₄. The obtained block g-C₃N₄ was ground to a powder and selected by a sifter.

2.1.2. Preparation of SiO₂ and SiO₂-loaded g-C₃N₄ (CN@SiO₂). Typically, the molar ratio of tetraethoxysilane (TEOS), absolute ethyl-alcohol (EtOH) and deionized water (H₂O) was measured and adjusted to 1 : 20 : 4, 100 mL EtOH was separated into two parts and a half of EtOH was mixed

with TEOS (denoted as liquid A), while the other part was mixed with deionized water and adjusted the pH to 2–3 with hydrochloric acid (denoted as liquid B). The obtained solutions were stirred for 30 min with magnetic stirring, and then A and B were mixed in equal volume. Next, different weights of g-C₃N₄ (0.4 g, 0.8 g, 1.2 g, 1.6 g and 2.0 g) were introduced to the sol-gel system separately, and then ammonium was added to the mixture with about 10 min stirring until the solution turned to thicker pulp. The gels were washed with deionized water several times to remove the anhydrous ethanol in the gels and then freeze-dried for 24 h to obtain the SiO₂ layers-coated g-C₃N₄ samples.^{26,27} The prepared samples were named as x-CN@SiO₂, where x is the mass fraction of g-C₃N₄ in the composite catalyst. A schematic of the preparation process is presented in Fig. 1.

2.2 Characterization

The crystalline phase was determined by X-ray diffraction (XRD) using a Bruker D8 diffractometer powder diffractometer (Cu K radiation). Fourier transform infrared spectra (FTIR) were recorded using INVEIO R in the mid IR range with the ATR accessory. The morphologies were acquired using a Tecnai G2F20 transmission electron microscopy system (TEM). X-Ray photoelectron spectroscopy (XPS) measurements were obtained with a Thermo Kalpha instrument. The Brunauer–Emmett–Teller (BET) surface area was measured using an OUADRASORB SI sorption analyzer based on nitrogen adsorption–desorption isotherms at 77 K. Besides, the UV-vis diffuse reflectance spectra were recorded on a UV-2600 UV/vis/NIR spectrophotometer, with BaSO₄ used as a reference. Also, the photoluminescence (PL) spectra were obtained using a Hitachi-F7000 fluorescence spectrophotometer.

Photoelectrochemical measurements were performed on a CHI660E electrochemical workstation using a standard three-electrode cell with Pt wire as the counter electrode and Hg/Hg₂Cl₂ (in saturated KCl) as the reference electrode. A solar simulator with a 300 W Xe lamp served as a light source, and the irradiation intensity was 100 mW cm⁻² at the reaction liquid level with an irradiance meter, and 0.5 M Na₂SO₄

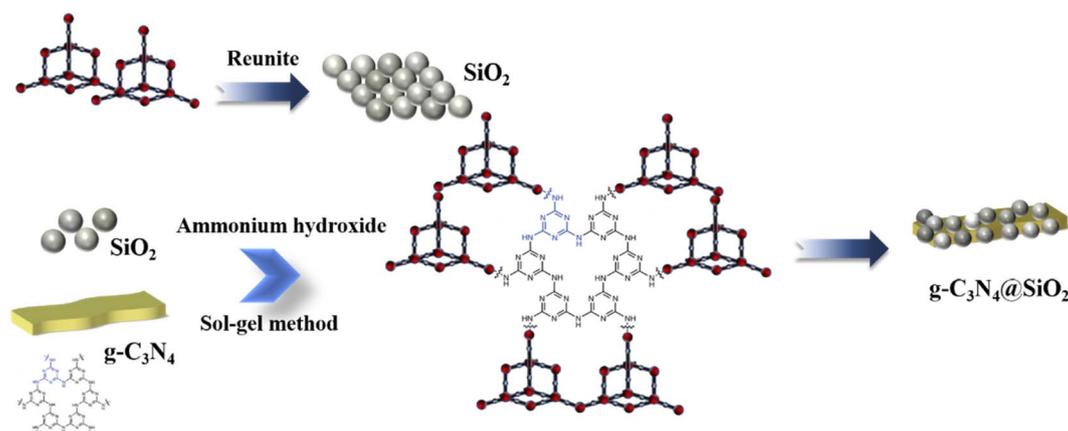


Fig. 1 Schematic showing the preparation process for the photocatalyst samples.



solution was used as the electrolyte. The working electrode was prepared as follows: 20 mg of the ground sample was mixed with 1 mL *N,N*-dimethylformamide (DMF), and then 0.15 mL of the resultant suspension was uniformly dropped onto an ITO glass and then calcined at 300 °C for 1 h under a nitrogen atmosphere.

2.3 Photocatalytic organic pollutants degradation

The photocatalytic organic pollutants degradation tests were performed at ambient temperature in a thermostatic reactor.²⁸ For each sample, 100 mg catalyst was dispersed in 100 mL (10 mg L⁻¹) pollutant solutions (RhB or antibiotic) in a Pyrex photocatalytic reactor. The sample was kept in the dark for 20 min prior to irradiation for achieving adsorption-desorption equilibrium. After reaching equilibrium, a 300 W xenon lamp (Micro-solar 300) was used as the simulated light source, and the irradiation intensity was 100 mW cm⁻² at the reaction liquid level as measured with the irradiance meter. The concentration of RhB or antibiotic was measured using a UV-2600 spectrophotometer at 10 min intervals. The degradation rate (η) of RhB or antibiotic was calculated as: $\eta(\%) = (1 - C/C_0) \times 100\%$, where C is the tested concentration of the pollutants after reaction, and C_0 represents the initial concentration of the pollutants.^{29,30}

2.4 Cyclic tests for the photocatalytic degradation of organic pollutants

The cyclic tests for the photocatalytic degradation of RhB and antibiotics were performed under visible light. Specifically, the experiments were carried out in a photocatalytic reactor irradiated by a solar simulator with a 300 W xenon lamp as the light source, and the irradiation intensity at the reaction liquid surface was 100 mW cm⁻². RhB and antibiotics were selected as the target contaminant, and the initial concentration was 10 mg L⁻¹. In a typical photocatalysis experiment, 100 mg photocatalyst, 100 mL RhB and antibiotics (10 mg L⁻¹) were dispersed into a photocatalytic reactor to form a suspension. Before xenon lamp irradiation, the suspension was stirred in the dark for 10 min to establish an adsorption-desorption balance, and were then exposed to visible light. To determine the concentration of the solution, 1 mL suspension was removed at a predetermined interval and put to rest to obtain the clarified solution. The degradation products were identified using a UV-2600 spectrophotometer.

2.5 Active species trapping experiments

The active species for the pollutants (RhB or antibiotics) degradation were evaluated by capture experiments.^{31,32} Typically, triethanolamine (TEOA), benzoquinone (BQ) and isopropanol (IPA) were used to capture the hydroxyl radicals ($\cdot\text{OH}$), superoxide radicals ($\cdot\text{O}_2^-$) and holes (h^+), respectively. The process followed for the active species trapping experiments was similar to that for the RhB and antibiotic degradation experiments. Before adding the photocatalyst, scavengers were introduced into the pollutant solutions, respectively.

3. Results and discussion

3.1 Morphological analysis

In order to study the morphology of the prepared samples, SEM, TEM and EDS mapping images of SiO₂, g-C₃N₄ and 1.2-CN@SiO₂ were obtained and are shown in Fig. 2. Fig. 2a–c are the SEM images of SiO₂, g-C₃N₄ and 1.2-CN@SiO₂, respectively. In Fig. 2a, it can be seen that the morphology of SiO₂ was spherical like, with many pores in the stacked planes and a particle size less than 500 nm, which are beneficial for the adsorption of reactants.³³ Fig. 2b indicates that the morphology of g-C₃N₄ showed a structure with layers of materials stacked on the surface and almost no pores in the two-dimensional plane, suggesting a poor adsorption ability compared with that of SiO₂.³⁴ As shown in Fig. 2c, the surfaces of the stacked g-C₃N₄ were covered by SiO₂ nanoparticles and the covered SiO₂ nanoparticles could improve the adsorption ability. Fig. 2d and e show enlarged TEM images of the 1.2-CN@SiO₂ and SiO₂ nanoparticles, respectively. It can be seen that the stacked g-C₃N₄ had no pores and SiO₂ nanoparticles were coated on the surface of g-C₃N₄ (Fig. 2d). The TEM image of SiO₂ nanoparticles (Fig. 2e) also showed that many pores existed in the planes of the coated layers. Based on the above analysis, it could be inferred that SiO₂ nanoparticles covered the surface of g-C₃N₄ with many pores existing, which could enhance the adsorption ability of the SiO₂ layers-coated g-C₃N₄.

Furthermore, the EDS mapping images of 1.2-CN@SiO₂ and corresponding C, N, O and Si elements were investigated and are shown in Fig. 2f and g, from which it could be seen that C and N elements were distributed uniformly with that of O and Si elements, which further illustrated that g-C₃N₄ was covered by SiO₂ nanoparticles uniformly. Herein, it could be concluded that the SiO₂ nanoparticles coating on g-C₃N₄ was successfully and the nanoparticles were distributed uniformly.

3.2 Crystal phase analysis

The XRD patterns of SiO₂, g-C₃N₄ and *x*-CN@SiO₂ were used to analyze the crystal phases of the samples, and the results are shown in Fig. 3a. It could be seen that g-C₃N₄ displayed a strong peak at 27.4°, which was generated from diffraction from the interaction of the layers, while the weak peak at 13.5° was from the interaction of the triazine rings. The wide diffraction peak at 22.5° was generated from the amorphous SiO₂ nanoparticles.³⁵ For the SiO₂ layers-coated g-C₃N₄ samples, a peak for g-C₃N₄ (27.4°) could be detected due to the existence of g-C₃N₄, and the intensity of this peak gradually increased with the increase in g-C₃N₄ amounts. These results suggest g-C₃N₄ was successfully composited with SiO₂ nanoparticles, and the crystals of g-C₃N₄ were not destroyed in the coating process.

The FTIR spectra of SiO₂, g-C₃N₄ and *x*-CN@SiO₂ were used to determine the structures of the coated samples and the results are shown in Fig. 3b. For g-C₃N₄, the broad peak between 2800 and 3400 cm⁻¹ corresponded to the stretching vibration of N–H at the end of the triazine ring, while the peaks between 1634 and 1230 cm⁻¹ were related to the stretching vibration of the C–N triazine ring, and the peak around 807 cm⁻¹ was the



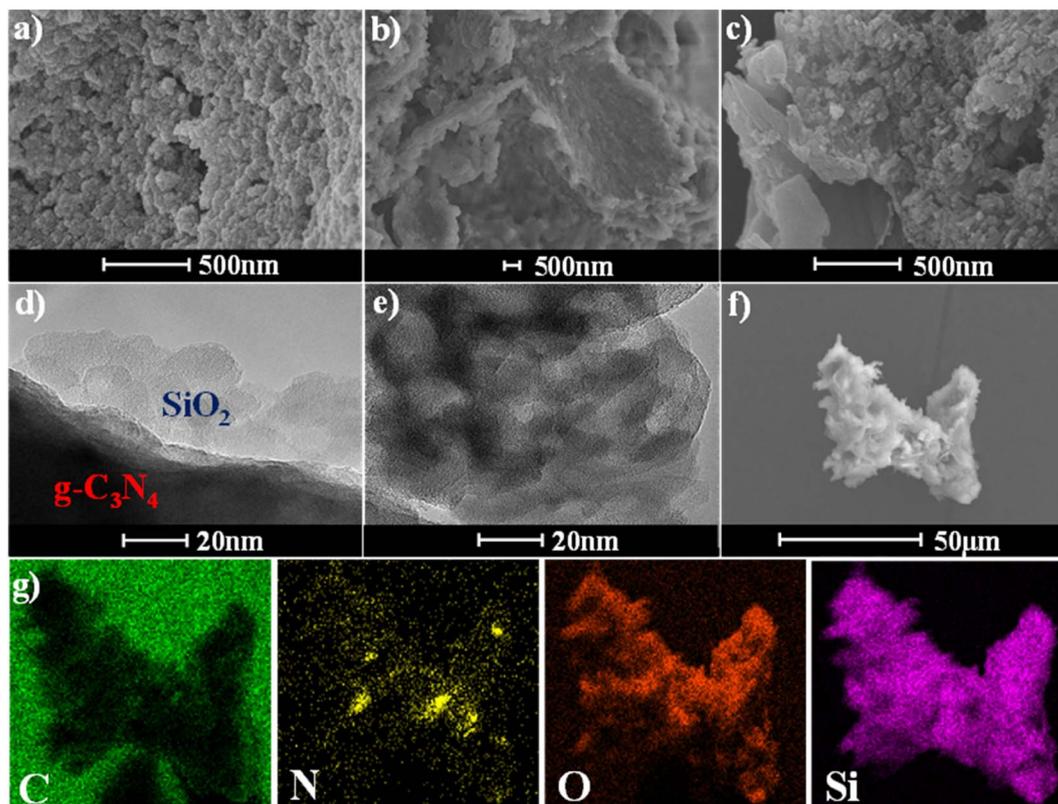


Fig. 2 SEM images of (a) SiO₂, (b) g-C₃N₄ and (c) 1.2-CN@SiO₂. TEM images of (d) 1.2-CN@SiO₂ and (e) SiO₂, EDS mapping images of 1.2-CN@SiO₂ corresponding to the (f) SEM image, and (g) element distribution maps.

binding vibration of the triazine ring.^{36,37} For SiO₂ nanoparticles, the broad peak at 3400 cm⁻¹ corresponded to the anti-symmetric stretching vibration of the -OH group, while the peak at 1630 cm⁻¹ was due to the -OH vibration of water adsorbed on the SiO₂ surface, and the peak around 967 cm⁻¹ was the Si-OH vibration of the SiO₂ surface and that at 800 cm⁻¹ was the Si-O vibration of SiO₂. The peaks for the vibrations of C-N, triazine rings, and those of Si-O, Si-OH, and -OH vibrations of SiO₂ nanoparticles were not changed in the composite catalyst, also indicating that the main molecular structures of g-C₃N₄ and SiO₂ were not destroyed. The main difference was that the broad peak of g-C₃N₄ at 3000–3500 cm⁻¹ in the composite catalyst had disappeared, which was mainly due to the connection of the amino group and SiO₂ layers, leading to the disappearance of the broad peak at the edge of g-C₃N₄. These results show that the coated catalyst still reserved the typical features of SiO₂ and g-C₃N₄.

The UV-vis spectra were used to identify the light adsorption abilities of SiO₂, g-C₃N₄ and x-CN@SiO₂ and the results are shown in Fig. 3c. For the SiO₂ nanoparticles, almost no obvious absorption edge was observed and these showed a poor adsorption ability in the UV and visible regions, which means the introduced SiO₂ nanoparticles had no effect on irradiated light. For g-C₃N₄, the adsorption edge was located at about 460 nm, which exhibited an intense adsorption ability in the ultraviolet regions and weak one in visible regions. For the x-CN@SiO₂ samples, the absorption intensity in the visible-light

region was lower than that of g-C₃N₄ because of the existence of SiO₂ reflected irradiated light. From the band gap patterns (Fig. 3b), it could be seen the energy band of the composite was smaller than that of the pristine g-C₃N₄.

The XPS spectra of g-C₃N₄ and 1.2-CN@SiO₂ were used to identify the chemical composition and chemical state of the catalyst, and the results are shown in Fig. 4. In the survey spectra (Fig. 4a), strong peaks were observed at 290, 400, and 530 eV corresponding to the typical peaks of the C 1s, N 1s, and O 1s spectra. Compared with that of g-C₃N₄, the new peaks at 105 and 160 eV could be attributed to the 2p spectra and 2s spectra of the Si atom, respectively.³⁸ Besides, the intensity of the O 1s peak was enhanced while that of N 1s peak was decreased, indicating the g-C₃N₄ was composited with SiO₂ nanoparticles by chemical bonding and not just a simple physical contact, which accorded with the FTIR analysis in Fig. 4b. The C 1s spectrum (Fig. 4b) of g-C₃N₄ was similar to that of 1.2-CN@SiO₂, whereby the peaks at 284.6, 287.9, and 286.0 eV could be attributed to C-C, C=N and N-C=N, respectively, and indicated that the Si atoms did not form chemical bond with C atoms in the composite process. For the N 1s spectrum of 1.2CN@SiO₂ (Fig. 4c), the peaks at 398.5, 400.1, and 404.0 eV could be attributed to C=N-C, N-(C)₃, and C-N-H bonds, respectively. Moreover, the peaks at 533.2 and 531.3 eV were attributed to the O atoms and oxygen vacancies in the siloxane group, respectively.



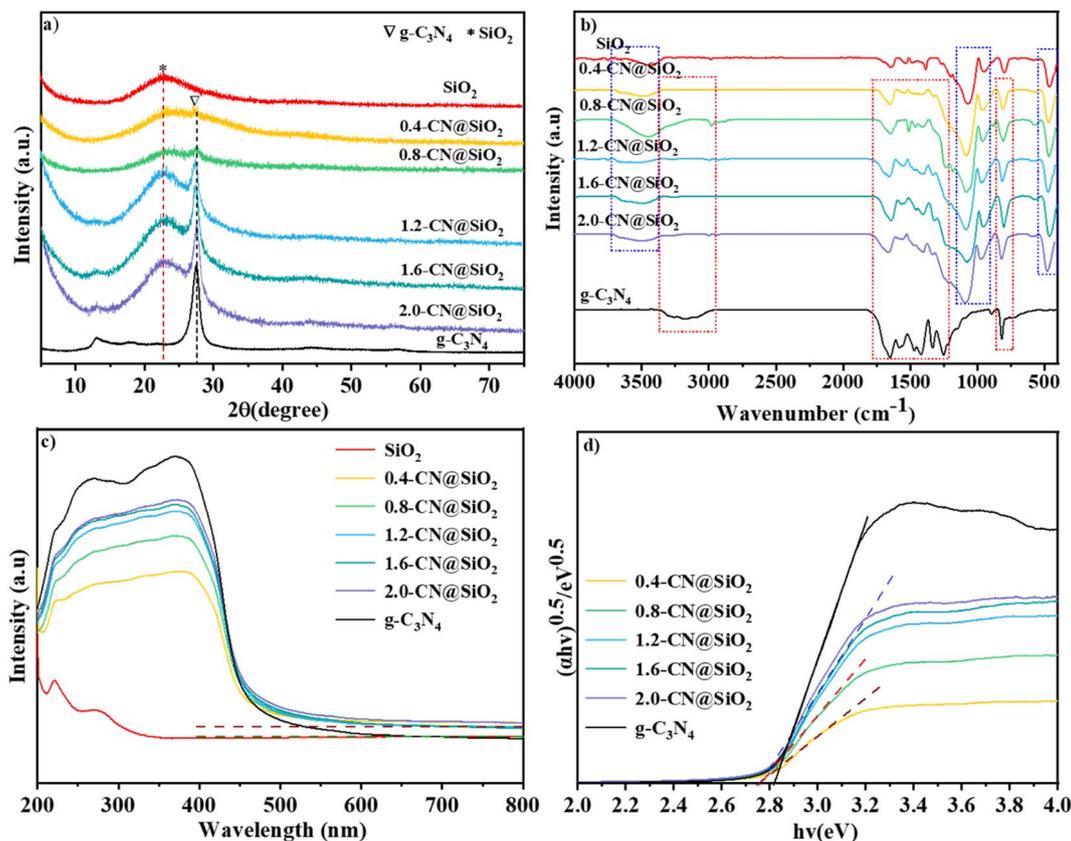


Fig. 3 XRD patterns of (a) SiO₂, g-C₃N₄ and composite samples, FTIR patterns of (b) SiO₂, g-C₃N₄ and x-CN@SiO₂. (c) UV-Vis and (d) bandgap patterns of SiO₂, g-C₃N₄ and x-CN@SiO₂.

3.3 Photocatalytic performance analysis

Tests into the photocatalytic degradation of RhB and antibiotics were conducted to study the performance of the composite catalyst, and the results are shown in Fig. 5.^{39,40} Fig. 5a presents the series of adsorption and degradation curves for the photocatalysts, where it could be seen that the adsorption efficiency (−20 min to 0 min) of g-C₃N₄ was the worst among the investigated samples, and that the adsorption properties were improved with the increase in SiO₂ layers. The highest adsorption efficiency of bare SiO₂ was equal to that of 0.4-CN@SiO₂ and was superior to that of the other samples, which may have been due to the SiO₂ nanoparticles, as more nanoparticles could adsorb more reactants. However, the photocatalytic degradation rate of SiO₂ nanoparticles could be neglected and the performance was enhanced with the increase in the amount of g-C₃N₄. To balance the adsorption property and degradation property, the most suitable amount of g-C₃N₄ was optimized at 1.2-CN@SiO₂, and the ideal removal rate of RhB was within 30 min. We used a first-order kinetics model to evaluate the degradation rate of RhB, as shown in Fig. 5b. For 1.2-CN@SiO₂, the rate constant was calculated to be 0.01918 min^{−1}, which was numerically lower than that for g-C₃N₄. It is worth noting that the presence of SiO₂ nanoparticle layers improved the adsorption performance of the composite catalyst,^{41,42} and helped realize the coordination between the adsorption and

degradation processes in the photocatalytic degradation of organic pollutants. The intermediate products of RhB degradation on g-C₃N₄ and 1.2-CN@SiO₂ were investigated by liquid chromatography-mass spectrometry and the results are shown in Fig. 5c and d, respectively. After 30 min degradation, the charge mass ratio of the intermediate products on g-C₃N₄ (Fig. 5c) ranged from about 200 to 720, meanwhile, there was a much higher charge mass ratio generation of intermediate products. Compared with that of 1.2-CN@SiO₂ (Fig. 5d), the charge mass ratio of the intermediate products was much lower (ranging from about 200 to 370).

The performances of the composite catalysts were further studied in the degradation of antibiotics based on the excellent degradation performance of RhB (Fig. 5e and g).⁴³ It was obvious that 1.2-CN@SiO₂ still exhibited the best photocatalytic degradation efficiency, reaching 89% within 30 min, and the K_{ap} was 0.02523 min^{−1} for 1.2-CN@SiO₂. According to the liquid chromatography-mass spectrometry results, the intermediate products from antibiotics degradation on g-C₃N₄ and 1.2-CN@SiO₂ were investigated, and the results are shown in Fig. 5g and h, respectively. After degradation for 30 min, 1.2-CN@SiO₂ had a much smaller charge mass ratio than g-C₃N₄.

The stability of the 1.2-CN@SiO₂ photocatalyst was tested by cyclic experiments. As shown in Fig. 5i and j, after cycling for 5 cycles under the same conditions, the degradation efficiency of



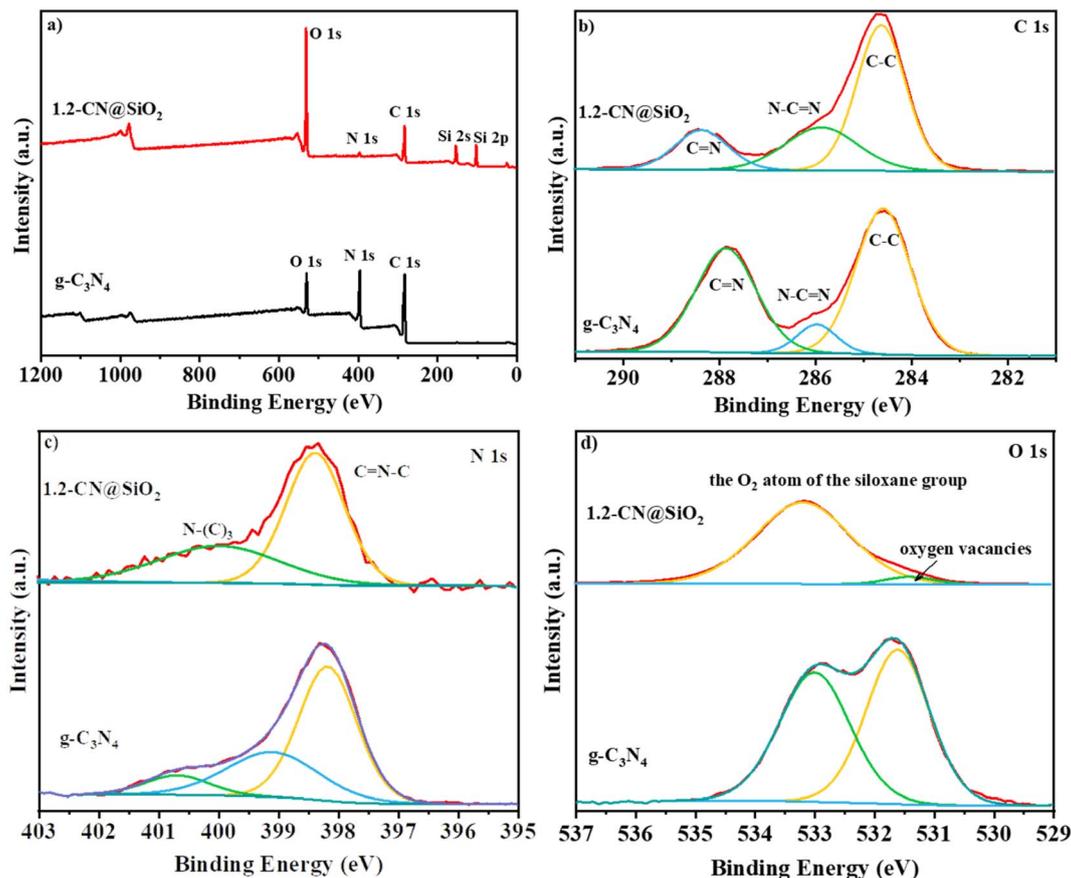


Fig. 4 XPS (a) survey spectra, (b) C 1s spectra, (c) N 1s spectra and (d) O 1s spectra of g-C₃N₄ and 1.2-CN@SiO₂.

1.2-CN@SiO₂ decreased slightly, indicating that the 1.2-CN@SiO₂ photocatalyst had favorable stability and reusability. The removal of organic pollutants by SiO₂ nanoparticles was mainly through adsorption, and the removal efficiency of the pollutants reached 46–68% after the end of the dark adsorption (Fig. 5k and l); whereas pristine C₃N₄ had a small specific surface area (10.24 m² g⁻¹) (Table 1) and poor molecular adsorption of organic pollutants, by contrast. Due to the introduction of SiO₂, the composite catalyst showed an excellent adsorption effect. After the photocatalytic experiments, the composite catalyst displayed an 85% degradation efficiency for organic pollutants, realizing the adsorption–photocatalytic collaborative regulation of organic pollutants and their intermediate products.⁴⁴

3.4 Photocatalytic mechanism analysis

The particle size is a key factor in catalysis and from the results shown in Fig. 6a it can be seen the sizes of SiO₂, g-C₃N₄ and 1.2-CN@SiO₂ were different. The particle size of SiO₂ was centered around 300 nm while that of g-C₃N₄ was about 600 nm, and the particle size even increased to 600–1200 nm. To study the improved adsorption properties of the samples, the specific surface area and pore size of the photocatalysts are other factors to consider for photocatalysts. Consequently, nitrogen adsorption–desorption isotherms and the hysteresis loops of SiO₂, g-

C₃N₄ and 1.2-CN@SiO₂ were investigated and the results are shown in Fig. 6b. The isothermal curve of g-C₃N₄ belonged to a H3 hysteresis loop, indicating that it was a slit formed by the accumulation of lamellar particles, while the isothermal curve of SiO₂ belonged to an H4 hysteresis loop, indicating it was due to the mutual accumulation of microspheres on the surface of SiO₂. Further, 1.2-CN@SiO₂ displayed an H4 hysteresis loop in the low and medium pressure regions, while it showed an H3 hysteresis loop in the high pressure region.^{45,46} The accumulation of slit holes on the surface of microspheres, and then the accumulation of slit holes between microspheres and lamellar particles. The specific surface areas of each catalyst calculated through the BET equation are shown in Table 1. Obviously, the specific surface area of SiO₂ was 33 times higher than that of g-C₃N₄ due to its porous structure. The specific surface area of the composite catalyst exhibited a regular decrease due to the possibility of incomplete filling of the SiO₂ pores with g-C₃N₄. However, the specific surface area of the composite catalyst was greater than that of pristine g-C₃N₄, which provides the possibility for adsorbing macromolecular organic pollutants. For SiO₂ and 1.2-CN@SiO₂, the pore-size distribution was between 2 and 5 nm, due to the fact that SiO₂ particles were uniformly sized microspheres, and so the cumulative pore-size distribution was calculated according to the BET characterization with the BJH fitting method (Fig. 6c and Table 1). The main pore-size



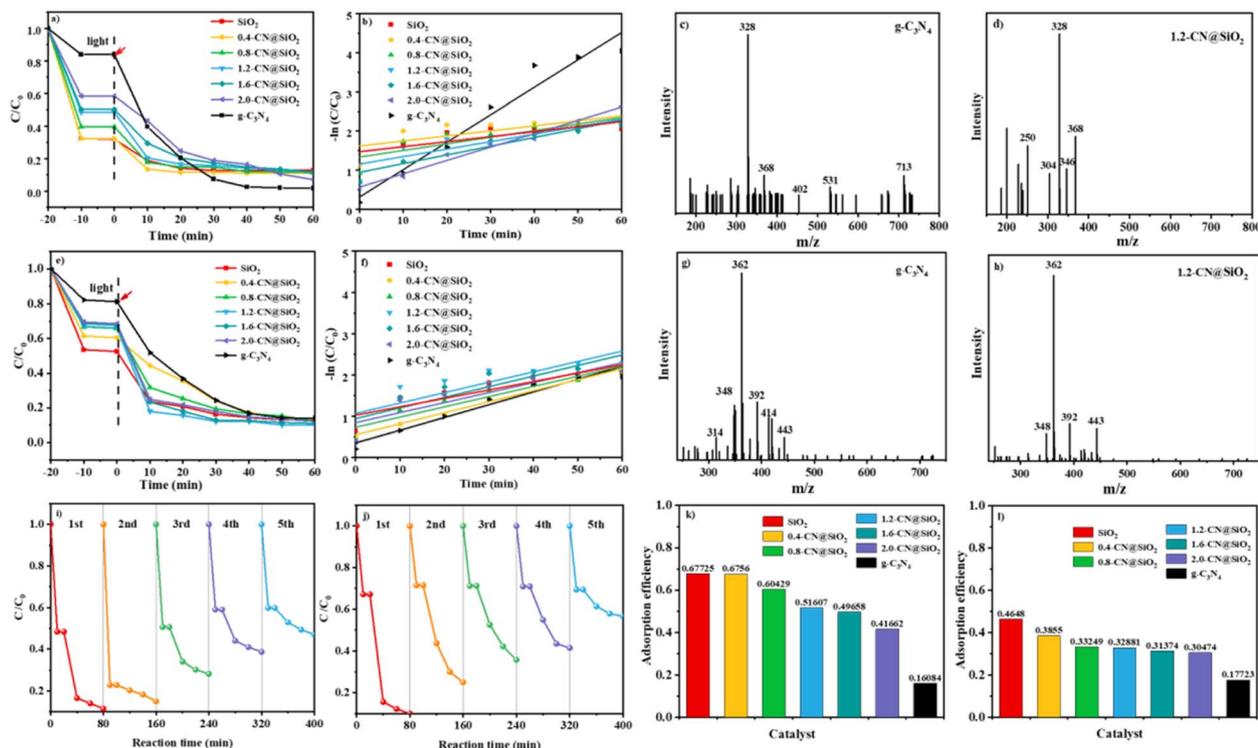


Fig. 5 RhB degradation of the (a) instantaneous concentration, and (b) kinetic plot of RhB dye degradation by the composite photocatalysts. (c and d) Mass spectra of the degradation products with $g\text{-C}_3\text{N}_4$ and 1.2-CN@SiO₂ as catalysts and 30 min irradiation; antibiotic degradation showing the (e) instantaneous concentration, (f) kinetic plot for antibiotic dye degradation by the composite photocatalysts (g and h) mass spectra of the degradation products with $g\text{-C}_3\text{N}_4$ and 1.2-CN@SiO₂ as catalysts and 30 min irradiation. (i and j) Recycled photodegradation of RhB and antibiotic dyes over the optimal 1.2-CN@SiO₂ photocatalysts. (k and l) Adsorption efficiency of the catalyst for RhB and antibiotics in 10 minutes.

Table 1 Specific surface areas, total pore volumes and average pore diameters of SiO₂, $g\text{-C}_3\text{N}_4$ and 1.2-CN@SiO₂

Sample	Surface area (m ² g ⁻¹)	Total pore volume (cm ³ g ⁻¹)	Average pore diameter (nm)
SiO ₂	775.01	0.53	3.94
1.2-CN@SiO ₂	529.17	0.38	4.00
$g\text{-C}_3\text{N}_4$	10.24	0.07	3.90

distribution of the catalysts was between 3.5 and 4.5 nm for the composite samples, where the average pore volume of $g\text{-C}_3\text{N}_4$ was larger due to its uneven sheet size and wide pore-size distribution. It was shown that the composite catalyst had a greater adsorption capacity for nitrogen with the same quality catalyst, so the composite catalyst had a better adsorption capacity for organic pollutants than pristine $g\text{-C}_3\text{N}_4$.

To further evaluate the contribution of various radicals, 1.2-CN@SiO₂ was treated with 1,4-benzoquinone (BQ), isopropyl alcohol (IPA), and disodium triethanolamine (TEOA) to remove O_2^- , OH , and photogenerated holes (h^+) before measuring the photooxidation efficiency, respectively. As shown in Fig. 6d, the O_2^- scavenger had the most significant inhibitory effect, with the efficiency dropping about 70%, while the second best inhibitor was h^+ , which reduced the efficiency about 45%. Although the

photooxidation efficiency fell substantially for 1.2-CN@SiO₂, the OH radical scavenger caused the lowest decrease (43%). These results indicated that O_2^- was the most active species for RhB degradation while OH and h^+ were had equal effects.

According to the double-layer capacitance (C_{dl}) analysis, the results for the electrochemically active surface area (ECSA) analysis from the cyclic voltammetry (CV) tests are shown in Fig. 7a and d, where the ECSA reflects the number of catalytic sites during the reaction, and a higher value of C_{dl} means more catalytic sites are exposed in the reaction solution system.^{47,48} The CV curves under different scanning rates for SiO₂, 1.2-CN@SiO₂ and $g\text{-C}_3\text{N}_4$ of 10–140 mV s⁻¹ are shown in Fig. 7(a)–(c). From Fig. 7d, it can be seen that the C_{dl} of 1.2-CN@SiO₂ was lower than that of SiO₂ but greater than that of $g\text{-C}_3\text{N}_4$, indicating that 1.2-CN@SiO₂ had more sites exposed than $g\text{-C}_3\text{N}_4$. The linear slope was equivalent to 10⁻³ times C_{dl} based on the linear fitting of the scanning rate by the capacitance current density of the non-Faraday interval double layer. As shown in Fig. 7d, 1.2-CN@SiO₂ had a C_{dl} of 25.75 $\mu\text{F cm}^{-2}$, which was much higher than that of $g\text{-C}_3\text{N}_4$ (20.42 $\mu\text{F cm}^{-2}$). The above analysis shows that the SiO₂-coated $g\text{-C}_3\text{N}_4$ photocatalysts could induce a greater ECSA, resulting in a higher exposed active surface area for reaction with the electrolyte, and enabling an improved mineralization rate for the degradation of organic pollutants.



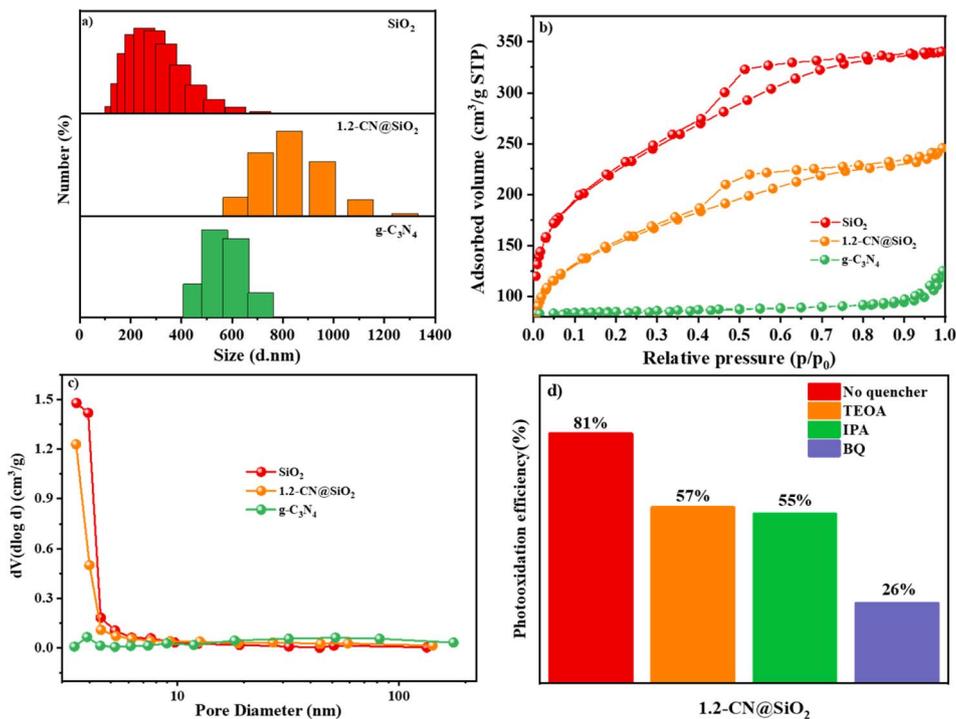


Fig. 6 Grain size distribution map (a), N_2 adsorption–desorption curves (b), pore-size distributions (c) of SiO_2 , $g-C_3N_4$ and $1.2-CN@SiO_2$. Photooxidation efficiency of RhB by radical trapping reagents treated with $1.2-CN@SiO_2$ (d).

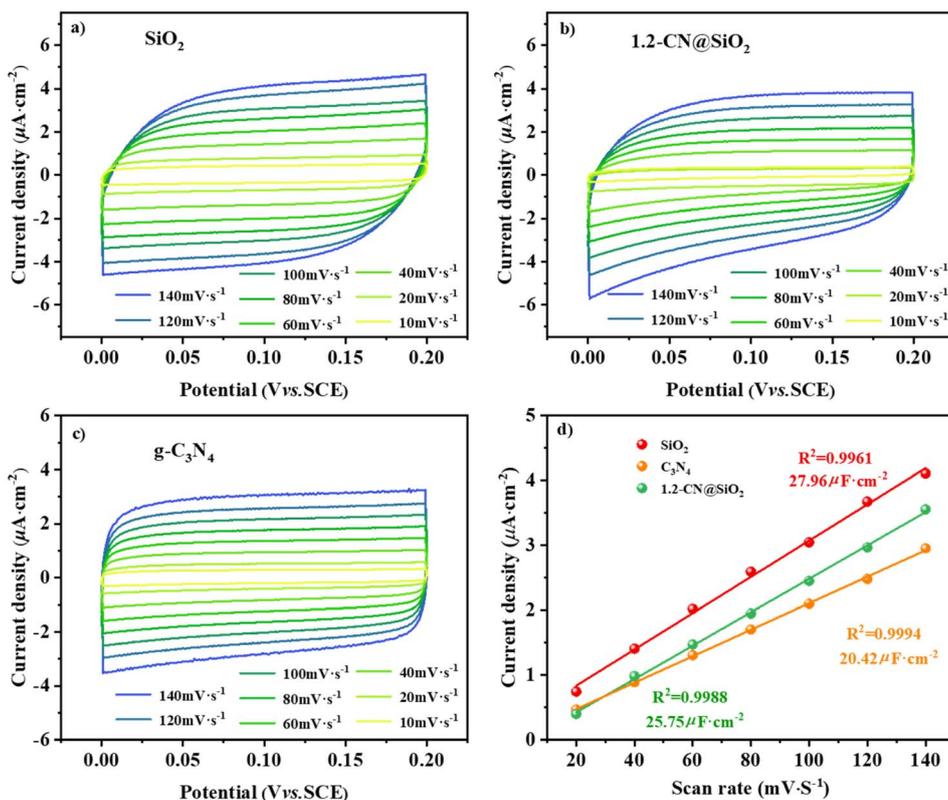


Fig. 7 CV curves at different scan rates for (a) SiO_2 , (b) C_3N_4 , and (c) $1.2-CN@SiO_2$. (d) Linear relation between the current density and scan rate.



The current densities generated from pristine $g\text{-C}_3\text{N}_4$, SiO_2 and $x\text{-CN@SiO}_2$ under simulated illumination are shown in Fig. 8. For $x\text{-CN@SiO}_2$, the composite catalyst still exhibited a certain current intensity and did not lose current intensity due to the loading of SiO_2 , indicating that the excitation electrons generated by the composite catalyst under illumination were mainly provided by $g\text{-C}_3\text{N}_4$. Also, the electrons of the composite catalyst could still be transported in the internal plane of the material (Fig. 8a).^{49,50} The impedance spectra further illustrated the resistance to internal electron migration between the composite catalysts. The radius is slightly larger of spectra in arc radius between the EIS Nyquist diagram of pristine $g\text{-C}_3\text{N}_4$, which is due to the SiO_2 layers coated on surface of $g\text{-C}_3\text{N}_4$ consistent with pristine $g\text{-C}_3\text{N}_4$, which suppressed the migration rate of charge carriers (Fig. 8b).

The fluorescence lifetime is the average residence time of electrons for returning from the excited state to the ground state. Fig. 8c shows the fluorescence lifetime curves of $g\text{-C}_3\text{N}_4$ and the composite catalysts, and the corresponding average lifetime values. The fluorescence lifetime of pristine $g\text{-C}_3\text{N}_4$ was 0.25 ns, while the fluorescence lifetime of the composite catalyst was 8.4 times higher. This was due to the fact that under the excitation of light, the photogenerated electrons migrated to the surface of SiO_2 and were consumed by water, resulting in an extended time for the electrons to return to the ground state. Therefore, the average lifetime for the composite catalyst was longer than for the pristine $g\text{-C}_3\text{N}_4$.

According to the PL spectra, the composite catalyst had wide and strong fluorescence emission peaks. Under light excitation,

the composite catalyst could generate electrons and holes, and the peak strengths of the composite catalyst were lower than those for the pristine $g\text{-C}_3\text{N}_4$, indicating that the recombination rate of photogenerated electrons and holes was lower for the composite catalyst than for the pristine $g\text{-C}_3\text{N}_4$, indicating that the loading of SiO_2 caused its electrons and holes to undergo catalytic reactions (Fig. 8d). The figure shows that SiO_2 had no fluorescence emission peak, indicating that the composite catalyst could generate photogenerated electrons and holes mainly due to $g\text{-C}_3\text{N}_4$.

Based on the above experimental data and analysis, a reasonable process for the degradation of organic pollutants by the composite catalysts is summarized in Fig. 9. After the composite catalyst is exposed, the organic pollutants (RhB, antibiotic drugs) are adsorbed onto the porous surfaces of the SiO_2 spheres due to the large specific surface area. Second, the adsorbed organic pollutants permeate into the internal section and contact with $g\text{-C}_3\text{N}_4$. Under light irradiation, the photogenerated electrons and oxidation holes are separated and the electrons migrate to the surface of $g\text{-C}_3\text{N}_4$ to participate in redox reactions. The migrated electrons contact with oxygen for superoxide radical generation, and the adsorbed organic pollutants react with superoxide radicals leading to the formation of complex macromolecular intermediate products. Fortunately, the coated SiO_2 layers can adsorb the intermediate products to further react with the superoxide radicals that circulate until small molecular products are generated and escape from the pores of the composite catalysts. This process can be described by the formulas below.

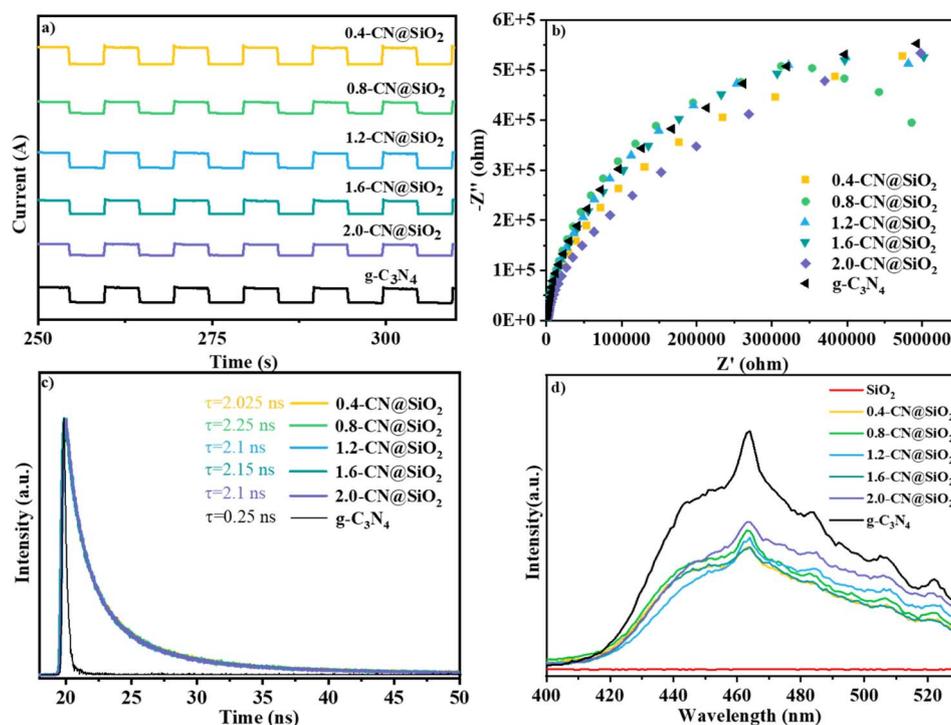


Fig. 8 (a) Transient photocurrent curves of $g\text{-C}_3\text{N}_4$ and $x\text{-CN@SiO}_2$, (b) EIS spectra of $g\text{-C}_3\text{N}_4$ and $x\text{-CN@SiO}_2$, (c) transient fluorescence spectra of $g\text{-C}_3\text{N}_4$ and $x\text{-CN@SiO}_2$, (d) PL spectra of $g\text{-C}_3\text{N}_4$ and $x\text{-CN@SiO}_2$.

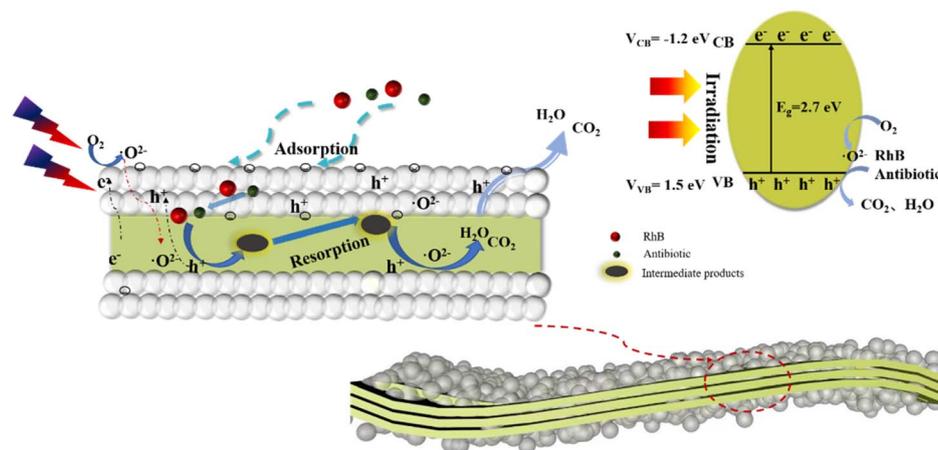
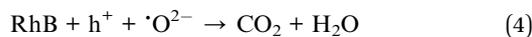
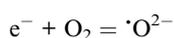
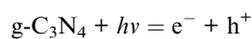


Fig. 9 Photocatalytic mechanism of micro-molecule products emission over the SiO₂ layers-coated g-C₃N₄ photocatalyst.



4. Conclusion

A SiO₂ layers-coated g-C₃N₄ composite photocatalyst was successfully prepared by a sol-gel method, which demonstrated an increased specific surface area and good adsorption property. The improved performance of the as-fabricated 1.2-CN@SiO₂ could be ascribed to the SiO₂ layers, which were beneficial for not only the adsorption of pollutants and intermediate products but also for prolonging the life time of the charge carriers. In the photooxidation mechanism, $\cdot\text{O}_2^-$ played a crucial role in pollutants degradation and the effects of $\cdot\text{OH}$ and h^+ equally contributed as well. The coated SiO₂ layers could adsorb the intermediate products to further react with superoxide radicals that circulate until small molecular products were generated and escaped from the pores of the composite catalysis.

Conflicts of interest

There are no conflicts to declare.

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